

## Feature

- High Precision GaAs process
- •High performance, shielded
- •GaAs substrate, 50Ω CPW output
- Au wire bonding, for MCM applications

## **Environmental Specifications**

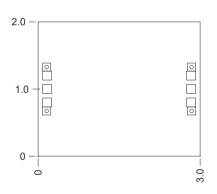
Operating Temperature	-55℃~+85℃	
Storage Temperature	-65°C~+150°C	
Max. Input Power	30dBm	

## **Electrical Specifications**(T<sub>A</sub>=+25°C)

Parameter	Min.	Тур.	Max.	Unit
Center Freq. (f <sub>0</sub> )	-	0.3	-	GHz
Pass band	0.25	-	0.35	GHz
Insertion Loss @ f <sub>0</sub>	-	-	3.0	dB
Return Loss	12	-	-	dB
Out of band Attenuation	≥35@80 MHz & 600MHz			dB

S2P file name: PDBF-R24\_R36-3C2.s2p

# **Outline Drawing**



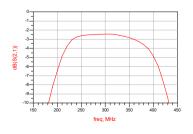
#### Notes:

- 1. Dimensions are in millimeters. Tolerance: ±0.05mm
- 2. Die thickness is 0.15 mm
- 3. Typical bond pad is 0.1x0.1 mm<sup>2</sup>.

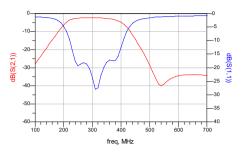
4. The bottom of the device is gold plated, should be grounded.

# **Typical Test Curves**

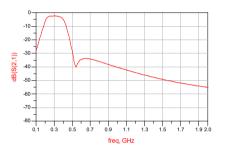
Insertion Loss VS Frequency (T<sub>A</sub>=25°C)



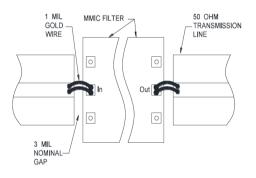




Broadband Insertion Loss VS Frequency (T<sub>A</sub>=25°C)



# **Recommended Assembly Diagrams**



### **Application Notes:**

1. The chip is back-metallized and can be die-mounted with AuSn eutectic preforms or with electrically conductive epoxy.

2. The die should be assembled on carriers like Kovar or Mu-Cu which have same Coefficient of thermal expansion. ( $5.8 \times 10-6$ /) with GaAs.

3. Recommend using  $\Phi 25 \text{um}$  Au wire for bonding, whose length is around 400 \text{um}.

4. Sinter by AuSn (80/20), which doesn't exceed 300°C within 30 seconds max.

4. Handle the chips in a clean environment. DO NOT attempt to clean the chip using liquid cleaning systems.

5. Handle the chip along the edges with a vacuum collet or with a sharp pair of bent tweezers.

6. The device is sensitive to ESD. ESD protection is required during storage and usage.

7. If you have any questions, please contact us.